

ADVERTISEMENT

Applications are invited from Indian nationals for the position of **Junior Research Fellow (JRF)** to work on a Lam research funded project on the development of thermal interface material (TIM) for silicon wafer industry. The candidate will have opportunity to enroll for PhD program if they satisfy institute eligibility criteria.

Post-1: Junior Research Fellow (JRF)

Position: 1.

Duration: 1.5 years or till the completion of the project, whichever is earlier. However, after every six months, the progress of the candidate will be reviewed for further extension.

Emoluments: 31000 pm + HRA (as applicable).

Essential Qualifications:

Post Graduate degree (M.Tech/MSc) in Mechanical/Physics/Materials Science or related discipline with GATE qualified.

Desirable: Since the project involves development of thermal interface material based on graphene/vertically aligned CNTs. The candidate earlier worked on TIM, thermal conductivity measurements, thermal management of electronics will be given a preference.

The applicants must send the following documents latest by November 20, 2021 through an e-mail at prabhat@iitrpr.ac.in. Please include Thermal Interface Materials in the subject line of your email.

- A one page cover letter describing your suitability to the post.
- Curriculum Vitae with complete qualification and experience details.
- Copy of GATE score.

The shortlisted candidates shall be called for interview. Please note that no TA/DA will be given to the candidates attending the interview.

For any related query, please contact

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JRF link: <http://www.iitrpr.ac.in/jobs/project-positions>